Tailoring perpendicular magnetic anisotropy with graphene oxide membranes†

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Graphene oxide (GO) membranes have been widely explored for their excellent physical and chemical properties, and abundant functional groups. In this work, we report the improvement of the perpendicular magnetic anisotropy (PMA) of CoFeB thin films by applying a coating of GO membranes. We observe that the PMA of the CoFeB/MgAl-O stacks is strongly enhanced by the coating of GO membranes and even reaches 0.6 mJ m⁻² at room temperature after an annealing process. The critical thickness of the membrane-coated CoFeB for switching the magnetization from the out-of-plane to the in-plane axis exceeds 1.6 nm. First-principle calculations are performed to investigate the contribution of the GO membranes to the magnetic anisotropy energy (MAE). Due to changes in the hybridization of 3d orbitals, varying the location of the C atomic layer with Co changes the contribution of the Co–C stacks to PMA. Thus, the large PMA achieved with GO membranes can be attributed to the orbital hybridization of the C and O atoms with the Co orbitals. These results provide a comprehensive understanding of the PMA and point towards opportunities to achieve multifunctional graphene-composite spintronic devices.

Two-dimensional materials, such as graphene, black phosphorus, MoS₂, and BN, are considered to be essential materials in the post-Moore era.¹⁻³ In addition to applications in electronic and optical devices, two-dimensional materials are also used in a variety of functional devices.⁴⁻⁶ Graphene-based materials especially have the potential to replace silicon as the primary material in a new generation of electronic devices.⁷ The high mobility, low spin–orbit interaction, and long spin lifetime of graphene make it an attractive medium for planar spin transport, enabling the realization of spintronic devices with new performance capabilities.⁸⁻¹²

Ferromagnetic electrodes in magnetic tunnel junctions that possess perpendicular magnetic anisotropy (PMA) have been widely studied because of their potential to downscale the size of storage cells and enhance thermal stability.¹³⁻¹⁴ A large PMA is an essential element of magnetic random-access memory (MRAM) with ultra-high density integration and low power consumption.¹⁵⁻¹⁶ To date, several graphene-based PMA spin electronics have been demonstrated.¹⁷⁻¹⁸ Recently, graphene oxide (GO) membrane, a chemical derivative of graphene with oxygen functionalities, has attracted great interest due to its exceptional functional group and scale-up production.¹⁹⁻²¹ However, the effect of GO membrane on interfacial PMA has not yet been demonstrated. In this paper, the PMA of GO membrane-coated CoFeB thin films sandwiched between layers of Ta and MgAl-O are investigated both experimentally and theoretically. Our results show that the combination of GO membranes with a ferromagnetic layer can extend the functions of the thin films and the development of multifunctional graphene-composite spintronic devices.

Experiment

Experiments were carried out on sputter-deposited films with a layered structure of substrate/Ta(6)/Co₄₀Fe₄₀B₂₀(t = 0.8–1.6)/MgAl–O(2)/Ta(3); the numbers in parentheses represent the thickness of the unit in nanometers. An MgAl–O layer was formed by RF sputtering from a sintered stoichiometric MgAl₂O₄ target. The films were annealed at 300 °C in a vacuum with a perpendicular magnetic field of about 8000 Oe for 1 hour. In order to improve the wettability of the films, the films were processed with oxygen plasma (Branson/IPC 3000 Plasma
Asher, USA) for 20 min before depositing the GO membranes. The GO membranes were prepared by an ultrasonic-aided spray-casting system using commercial GO aqueous dispersions, presented in Fig. 1a. During the deposition process, the temperature of the films was kept at 25 °C, to maintain a proper evaporation rate of water molecules. The deposition process was repeated five times, with each single deposition lasting 8 s. The Raman spectra from two points on the films were obtained (Fig. 1b). The characteristic peaks, D, G, and 2D, are shown in the curves, their similarity clearly indicating the uniformity of the GO membranes. Since the roughness of the GO membranes has a significant influence on the performance of electronic devices, the surface morphology and a cross-sectional HRTEM image of the membrane-coated samples are shown in Fig. 1c and d, respectively, to demonstrate the good quality and relatively sharp interface of the GO membranes.

Results and discussion

Fig. 2 shows the in-plane and out-of-plane magnetization (M–H) curves of the samples with and without the coating of GO membranes. The thickness of the CoFeB layers varies from 0.8 nm to 1.6 nm. The blue and red lines represent the out-of-plane (OP) and in-plane (IP) hysteresis curves with the magnetic field applied perpendicular or parallel to the plane of the samples, respectively. For the as-deposited film (not annealed), the OP direction was the easily magnetized axis when \( t_{\text{CoFeB}} = 0.8 \) nm, showing a well-squared shape. In the as-deposited samples without the GO membrane coating, the IP direction was the easily magnetized axis when \( t_{\text{CoFeB}} = 1.4 \) nm (Fig. 2a); therefore, the turning point from OP to IP being the easily magnetized axis was \( t_{\text{CoFeB}} = 1.3 \) nm. On the other hand, the turning point from OP to IP being the easily magnetized axis was \( t_{\text{CoFeB}} = 1.4 \) nm in as-deposited samples with the GO membrane coating, as shown in Fig. 2b; the critical thickness for switching from the OP to the IP easy axis was extended by the GO membrane coating. Although the easy axis was IP when \( t_{\text{CoFeB}} = 1.6 \) nm in the as-deposited samples both with and without the coating of GO membranes, the perpendicular saturation field decreased from 3000 Oe to 2000 Oe with the coating, indicating an enhanced contribution of PMA in the magnetization process. The enhancement of PMA of the as-deposited samples with GO coating is attributed to the fact that during the fabrication of CoFeB layer with the coating of GO membranes, the samples were put onto the hot plate at the temperature of 65 °C to dry the water of the GO dispersions. This heating effect could improve the interface between CoFeB and MgAlO barrier a little bit, and then enhance hybridization of Co(Fe) 3d and O 2p orbitals. After annealing (see ESI†), the PMA was enhanced for samples with \( t_{\text{CoFeB}} \) from 1.0 to 1.4 nm, both with and without the GO membrane coating. The easy axis became OP with \( t_{\text{CoFeB}} = 1.4 \) nm in the annealed sample without the GO membrane, while it became OP with \( t_{\text{CoFeB}} = 1.6 \) nm in the annealed sample with the GO coating. Also, the in-plane saturation field increased from 2000 Oe to 4000 Oe in the coated samples with \( t_{\text{CoFeB}} = 1.4 \) nm. These results indicate that the coating of GO membranes can significantly improve the PMA of CoFeB thin film.
Generally, the effective magnetic anisotropy is composed of the contributions of the bulk anisotropy, the shape anisotropy, and the interfacial anisotropy. The effective anisotropy energy density ($K_u$) can be determined by taking the difference between the areas above the magnetization curves, measured along the hard and easy magnetic axes. Mathematically, $K_u$ can be given by

$$K_u = K_b - 2\pi M_s^2 + K_i/t_{\text{CoFeB}}$$

where $K_b$ can be estimated by $K_b = H_s M_s/2$, but it is more precise to be calculated by the subtraction of the integral area of in-plane $M-H$ curves from the out-of-plane $M-H$ curves; $H_s$ is the saturation field along the hard axis, $M_s$ the saturation magnetization, $K_b$ the bulk crystalline anisotropy and $K_i$ interfacial anisotropy, while $2\pi M_s^2$ and $t_{\text{CoFeB}}$ represent the shape anisotropy and the thickness of CoFeB, respectively. The plots of $K_u$ against $t_{\text{CoFeB}}$ are presented in Fig. 2d and e for the samples with and without the GO membrane coating. The transition from out-of-plane ($K_u > 0$) to in-plane ($K_u < 0$) magnetic anisotropy takes place close to $t_{\text{CoFeB}} = 1.3$ nm without the GO membrane coating, and $t_{\text{CoFeB}} = 1.4$ nm with the GO membrane coating (Fig. 2d), indicating that the GO membranes enhance the PMA. The enhancement of $K_u$ by the GO membrane coating is clearly seen in Fig. 2d and e, in which the values of $K_u$ for all of the coated samples (both as-prepared and annealed) are higher than those in the corresponding samples without the coating.

After annealing, the PMA of the samples both with and without GO membranes is strongly enhanced, except when $t_{\text{CoFeB}} = 0.8$ nm (Fig. 2e); a giant PMA of 0.6 mJ m$^{-2}$ is achieved for a 1.2 nm thick CoFeB layer with GO membranes. First-principle calculations have shown that the PMA in a CoFeB–MgO system is mainly influenced by the hybridization of either Co 3d and O 2p orbitals, or Fe 3d and O 2p orbitals. Considering the changes in the hybridization of Co or Fe 3d and O 2p orbitals under the annealing temperature ($300^\circ$C), the enhanced PMA was probably caused by the increase in oxygen content at the interface between CoFeB and MgAl–O, and the improved crystalline structure of CoFeB and MgAl–O. However, the diffusion of C atoms from the functional groups of the GO membranes partially hindered the crystallinity of the CoFeB film. For the samples with $t_{\text{CoFeB}} = 0.8$ nm, the PMA degradation probably originates from the inter-diffusion between Ta and CoFeB at the interface, and from the increased thickness of the magnetic dead layer.
dispersive spectrum (EDS) was used to characterize the elemental distribution and stoichiometry of the samples both with and without GO membranes. Fig. 3b shows the constituting elements from the chemical distribution maps, from which the line-averaged profiles of the chemical element maps were generated (Fig. 3c). The EDS images clearly reveal that the C atoms diffuse from the GO membranes to the interface between CoFeB and MgAl–O, even spreading into the CoFeB layer, unlike the CoFeB stacks without GO membranes. Here, we ascribe the PMA enhancement of the CoFeB layer with the coating of GO membranes to the hybridization of the C and Co(Fe) atoms, which is consistent with recent studies of PMA enhancement in graphene-coated and C-covered Co surfaces.79–81

Generally, the PMA of CoFeB/MgAlO or MgO structures arises from the hybridization between Co(Fe) 3d and O 2p orbitals,32,33 as also demonstrated by the PMA of CoFeB without GO coating in this work. In addition, the binding energy of C is in C–O and C–C functional groups are 284.8 eV and 286.3 eV, respectively, indicating that C exceptional functional groups diffuse much easily. As shown in EDS images, the C atoms diffused from the GO membranes to the interface between CoFeB and MgAl–O, even spreading into the CoFeB layer, unlike the CoFeB stacks without GO membranes. Based on above considerations, we think the carbon atoms play important role in the enhancement of PMA of CoFeB with GO coating, in contrast with pure CoFeB/MgAlO heterostructures. Therefore, we performed first-principle calculations using the Vienna ab initio Simulation Package (VASP)34–37 to better understand the enhancement of the CoFeB PMA by the GO membrane coating, especially the influences of carbon atoms with different distribution relative to Co. We modeled a Co/layered-carbon system, because it has a simple atomic structure and the relevant mechanisms are believed to be similar to those of CoFeB/MgAl–O. In our calculations, the Co film was 5 monolayers (ML), or 10 Å. The in-plane lattice constant of the Co surface was fixed to the calculated bulk value of 2.5 Å. Five atomic layers of Co were included in the periodic supercell with 10 angstroms of vacuum to mitigate the interaction with the imaged Co layers. The electron–electron exchange–correlation was presented by generalized gradient approximation (GGA)34 following Perdew–Burke–Ernzerhof (PBE).35 The cutoff energy was set to 500 eV, with a 23 × 23 × 1 Monkhorst–Pack k-point mesh.37 Taking the spin–orbit coupling (SOC) effect into account, the energetically favorable direction, i.e., the easy axis of spontaneous magnetization, was determined by calculating the magnetic anisotropy energy (MAE):38

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MAE = E_u - E_o \sim \xi^2 \sum_{ij u o} |\langle \psi_u | L_z | \psi_o \rangle|^2 - |\langle \psi_u | L_o | \psi_o \rangle|^2 / \epsilon_u - \epsilon_o
\]

where \(E_u\) and \(E_o\) are the total energy for magnetization in the [100] and [001] directions, respectively;35 \(\xi\) is the SOC amplitude constant; \(u\) and \(o\) represent the unoccupied and occupied states, respectively; \(\psi_u, \psi_o\) and \(\epsilon_u, \epsilon_o\) are the corresponding wave functions and eigenenergies; and \(L_u\) and \(L_o\) are the orbital angular momentum \(x\) and \(z\) components, respectively. The squared modulus of the atomic projected matrix elements \(|\langle \psi_u | L_z | \psi_o \rangle|^2 (i = z, x)\) are shown in Fig. 4, from which atomic contributions to the MAE can be deduced subtractively.32

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**Fig. 3** (a) Schematic of samples characterized by high-angle annular dark-field (HAADF) with line scan-energy dispersive spectra (EDS). (b) Elemental distribution and combined of all elements for the GO membrane–coated samples after annealing at 300 °C. Line profiles for individual elements extracted from the HAADF images of the annealed samples (c) with GO membranes and (d) without GO membranes. Here, the thickness of the CoFeB layer is 1.4 nm. The pink area represents the CoFeB thin layer and the MgAl–O barrier.
We first studied the MAE of the bare Co (001) surface, as shown in Fig. 4a. Fig. 4e shows the corresponding MAE contributions from the surface Co atom (circled). The dominant MAE contribution was positive and originated from the hybridization of the $d_{xy}$ and $d_{x^2-y^2}$ orbitals (labeled 1). The total MAE was calculated to be 0.62 mJ m$^{-2}$. Fig. 4b shows the atomic structure of the Co layer/double C atomic layers. The calculated MAE increased to 1.333 mJ m$^{-2}$. The MAE contributions from the interfacial Co atom (circled) are shown in Fig. 4f. Although the hybridizations of the $d_{xy}$ and $d_{x^2-y^2}$ orbitals (labeled 1 in Fig. 4e and f) and the $d_{yz}$ and $d_{xz}$ orbitals contributed less to the MAE, the contribution from the hybridization of the $d_{xy}$ and $d_{x^2-y^2}$ orbitals (labeled 5 in Fig. 4e and f) changed from negative to positive after introducing the C atoms, enhancing the overall MAE.

Experimentally, we found that the annealing process resulted in the partial diffusion of C through the CoFeB thin film, forming an additional counter interface. To take this additional interface into account, we built a structure of mono C atomic layer/Co layer/mono C atomic layer, as shown in Fig. 4c. The MAE further increased to 1.93 mJ m$^{-2}$, almost 1.5 times that of the Co/double C atomic layer structure. However, we did not observe a substantial MAE enhancement after annealing. To address the discrepancy between the experiment and the theoretical calculations, we assumed that a certain amount of C atoms remained in the Co, contributing to the MAE in a different way. We studied an interstitial site C in the center of a Co slab. We also compared several highly symmetric C interstitial sites in the central Co layer (labeled A, B, and C) and found that the interstitial site A was the most stable, as shown in Fig. 4d. The calculated MAE was 1.508 mJ m$^{-2}$, 1.5 times that of the Co/double C atomic layer structure. We analyzed the corresponding MAE contributions (Fig. 4g) from the Co atom in the layer next to the interface (circled). The MAE contribution changed from positive to negative during the hybridization of $d_{xy}$ and $d_{x^2-y^2}$ (labeled 1). The contributions to MAE from the interfacial Co in this case were almost identical to those from the interfacial Co atom in the case of the Co/double C atomic layer structure. Therefore, due to the adverse effect of the interstitial site C on MAE, the overall MAE enhancement was suppressed.

**Conclusion**

In summary, we investigated the magnetic characteristics of CoFeB stacks, with and without a coating of GO membranes, both theoretically and experimentally. All of the results confirm that the GO membranes dramatically enhanced the PMA of a CoFeB/MgAl-O system. Our experiments found that the critical thickness for switching from an out-of-plane to an in-plane easy axis exceeds 1.6 nm after coating the CoFeB stacks with GO membranes, resulting in a giant PMA of 0.6 mJ m$^{-2}$ when $t_{CoFeB} = 1.2$ nm. The PMA of Co with the C atomic layer in a different location was studied through first-principles calculations. The
PMA of the Co layers was mainly dominated by the interfacial 3d orbitals hybridization, even with an interstitial C defect. This comprehensive understanding of the PMA provides an alternative route for expanding the applications of GO membranes in graphene spintronics and for developing multifunctional graphene-composite spintronic devices.

Experimental section

Samples with GO membranes fabrication

A medical ultrasonic atomization nebulizer (Omrion Ultrasonic Nebulizer NB-150U, Japan) was used to prepare the fine mist of GO dispersion. To improve the wettability of the surface, the samples were processed by oxygen plasma (Branson/IPC 3000 Plasma Asher, USA) for 20 min before depositing the GO membranes. During the deposition process, temperature of the samples was set to be 25 °C for keeping a proper evaporation rate of water. The deposition process was repeated 5 times, with each single deposition lasting 8 s.

Raman spectroscopy

The Raman spectra were acquired using a Horiba Evolution Raman spectroscopy system.

Magnetic measurement

The magnetic characteristics of the samples both with and without GO membranes were measured with vibrating sample magnetometer (Micro-sense EZ-VSM).

Energy-dispersive X-ray spectroscopy

The elemental mapping shown in Fig. 3 was acquired using a built-in EDX measurement module in the STEM module of HITACHI S-4800 system. The probe size used in this case is 0.8 Å by FEI-Titan-G2 with Cs-corrected probe and it can distinguish 1 nm efficiently.

Conflicts of interest

There are no conflicts to declare.

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Notes and references